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MOLECULAR IMPRINTS PLACES NANO-LITHOGRAPHY TOOL AT CARDIFF UNIVERSITY

AUSTIN, Texas - Molecular Imprints, Inc. (MII), the world's leading manufacturer of Step and Flash Imprint Lithography (S-FIL™) equipment, announces the sale of an Imprio™ 55 system to Cardiff University's Manufacturing Engineering Centre (MEC), in the United Kingdom.

"We are very pleased to add prestigious Cardiff University to our customer base. The Imprio 55 is the perfect research tool to help the MEC continue to push the boundaries of nano-scale manufacturing," said Dr. Mark Melliard-Smith, CEO of Molecular Imprints.

Founded in 1996, the MEC is a cutting-edge research center dedicated to the development of Advanced Manufacturing and Information Technology. It has established an award-winning reputation for both academic excellence and successful partnering with industry.

"The Molecular Imprint nano-lithography machine is an excellent complement to the MEC's MicroBridge project, a programme funded by the DTI and the Welsh Assembly Government as part of the UK MNT Network. It offers a method for cost-effective Nano-patterning of larger surfaces by multiplying the capabilities of focus ion beam and electron beam lithography. This capability will allow the MEC to be at the forefront of technology development and offer companies an access to technology that underpins a range of new innovative products in organic nanoelectronics, MEMS/NEMS, advanced packaging, bio devices, optical components, etc." stated Stefan Dimov, *Dipl. Eng, PhD*, Professor of Advanced Manufacturing Technology and Deputy Director of the award-winning Manufacturing Engineering Centre at Cardiff University.

About Molecular Imprints Inc.

Molecular Imprints, Inc. (MII) is a global developer and manufacturer of nano-lithography systems for high resolution and for 3-dimensional pattern replication. The company has commercialized a proprietary imprint lithography technology (S-FIL™), which is a room temperature, low pressure, non-contact imprint process that has demonstrated sub-20 nanometer resolution. Molecular Imprints provides enabling lithography systems and technology for manufacturing applications in the areas of nano-devices, solid state lighting, silicon applications, micro optical components, and magnetic data storage applications. For more information, visit www.molecularimprints.com

About MEC

The Manufacturing Engineering Centre (MEC) is an award-winning R&D Centre of Excellence for Advanced Manufacturing and Information Technology. The ISO 9001:2000 accredited Manufacturing Engineering Centre (MEC) offers specialist services in Time Compression Technologies to companies of all sizes. The Manufacturing Engineering Centre (MEC) has an international reputation for its leading-edge research in Advanced Manufacturing and Information Technology spanning a broad spectrum of subjects. For more information, visit www.mec.cf.ac.uk